

1 **Fully automated, sequential focused ion beam milling**
2 **for cryo-electron tomography**

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22 **Abstract**

23 Cryo-electron tomography (cryoET) has become a powerful technique at the interface of
24 structural biology and cell biology, with the unique ability to determine structures of
25 macromolecular complexes in their cellular context. A major limitation of cryoET is its
26 restriction to relatively thin samples. Sample thinning by cryo-focused ion beam
27 (cryoFIB) milling has significantly expanded the range of samples that can be analyzed
28 by cryoET. Unfortunately, cryoFIB milling is low-throughput, time-consuming and
29 manual. Here we report a method for fully automated sequential cryoFIB preparation of
30 high-quality lamellae, including rough milling and polishing. We reproducibly applied
31 this method to eukaryotic and bacterial model organisms, and show that the resulting
32 lamellae are suitable for cryoET imaging and subtomogram averaging. Since our method
33 reduces the time required for lamella preparation and minimizes the need for user input,
34 we envision the technique will render previously inaccessible projects feasible.

35 **Introduction**

36 Cryo-electron tomography (cryoET) is a powerful imaging technique at the interface of
37 cell biology and structural biology, able to image cells in a near-native state and determine
38 the structure of macromolecular machines in their cellular context (Beck and Baumeister,
39 2016; Koning et al., 2018; Kooger et al., 2018; Oikonomou and Jensen, 2017; Plitzko et
40 al., 2017). CryoET is restricted to samples that are well below 800 nm in thickness and
41 therefore requires sample thinning techniques for specimens like mammalian cells, *C.*
42 *elegans*, yeast, cyanobacteria, or biofilms. Biological cryoFIB milling is an emerging
43 sample thinning technique, which uses a Gallium ion beam to ablate segments of the
44 sample in order to generate thin lamellae that can be imaged by cryoET (Marko et al.,
45 2007; Rigort et al., 2010). Unlike previous methodologies, cryoFIB milling produces
46 artifact-free specimens, in which *in situ* structural information is preserved. Its application
47 has led to important insights into mechanisms of cellular function (Albert et al., 2017;
48 Böck et al., 2017; Bykov et al., 2017; Cai et al., 2018; Chaikerasitak et al., 2019; Delarue
49 et al., 2018; Khanna et al., 2019; Mahamid et al., 2016; Rast et al., 2019; Swulius et al.,
50 2018; Weiss et al., 2019). Unfortunately, however, cryoFIB milling for cryoET is at an
51 early stage of technical maturation and the available techniques are highly manual
52 procedures with relatively low throughput.

53 In current lamella preparation workflows (Marko et al., 2007; Medeiros et al., 2018;
54 Rigort et al., 2010; Strunk et al., 2012; Zhang et al., 2016), samples are vitrified on
55 transmission electron microscopy (TEM) grids by plunge-freezing. Grids are then
56 transferred to a FIB-scanning electron microscope (SEM) instrument, where potential
57 targets are then identified by SEM and FIB imaging (Supplementary Fig. 1a/b). Using a
58 series of ‘rough milling’ steps, sections above and below the desired lamella are
59 sequentially removed by decreasing the separation between two milling areas and using
60 decreasing FIB milling currents (700 to 100 pA) (Supplementary Fig. 1c-e). Once the
61 lamella is thinned to ~500 nm, additional targets are identified and thinned by rough
62 milling in a similar manner. To generate lamellae with a final thickness of 100-250 nm,
63 the user returns to each target location and further thins (‘polishes’) each lamella using a
64 low (≤ 50 pA) current (Supplementary Fig. 1f).

65 This methodology allows the production of up to 16 lamellae in 10 h (Medeiros et al.,
66 2018), however, during such a session, the process requires constant attention from the

67 operator. The milling process has to be monitored and manual user input is required every
68 10-15 min, e.g. to execute a series of repetitive tasks such as target identification,
69 positioning milling patterns, changing FIB currents, and visually determining milling end
70 points. This results in a strenuous procedure with a low throughput relative to the time
71 invested by the user, as well as significant idle times due to delays in input from the
72 operator. To overcome these issues, automated sequential cryoFIB milling has become of
73 paramount interest for the field.

74 **Setup of an automated milling session**

75 Here we report, to our knowledge, the first automated sequential FIB milling method for
76 the preparation of lamellae for subsequent cryoET imaging. Automation was
77 implemented on the Zeiss Crossbeam 550 FIB-SEM instrument, using routines that are
78 available in the SmartFIB software package (Zeiss Microscopy GmbH, Oberkochen,
79 Germany). Particularly important are the modules for stage backlash and drift correction,
80 which are critical for reliable targeting of lamella preparation sites. This allows the user
81 to set up all milling targets and then execute milling in an unattended, fully automated
82 manner.

83 To begin an automated milling session, FIB current alignments are verified to ensure
84 accurate milling (Fig. 1a). Grids are then loaded into the FIB-SEM instrument. To
85 simplify navigation and target identification, an SEM grid overview image is captured
86 and linked to the stage coordinates as described in the methods. Using the overview image
87 for stage navigation, the first milling site is identified and centered in both the SEM and
88 FIB views (Fig. 1b). To improve the accuracy of mechanical stage movements, the stage
89 is backlash-corrected when moved during automation. To ensure accurate targeting of the
90 milling site, a series of operations is executed before saving the final target position (Fig.
91 1c). First, stage backlash correction is manually executed and the target is re-centered in
92 the FIB image. Second, the target's stage coordinates are saved to the stage navigation
93 menu. Third, the stage is manually moved off-target and automatically returned to the
94 saved target location (Fig. 1d). In case the target is *not* properly centered, the above three
95 steps are repeated (Fig. 1e), otherwise the user can proceed.

96 Next, patterns with specific currents for rough milling (e.g. 700, 300 and 100 pA) and
97 polishing (e.g. 50 pA) are manually placed onto the FIB image of the target (Fig. 1f/f').

98 This is achieved by either generating a new set of patterns or by loading previously
99 designed patterns, which is faster and results in more uniform lamellae. To further
100 improve the accuracy of targeting, we incorporated an additional targeting step based on
101 drift correction (Fig. 1f/f'). To implement, each set of milling patterns receives a drift
102 correction box, with user-defined dimensions, which is manually placed in a location
103 close to the target. By capturing and saving an image of the drift correction box, the
104 milling patterns are anchored to their positions on the target.

105 After saving the first target to the queue, further targets are added by repeating the
106 described procedure. This setup-procedure takes ~9 min per target.

107 **Processes during automated milling session**

108 To begin sequential automation, exposure of the rough milling patterns that are saved in
109 the queue is started (Fig. 1g). For each target, the stage automatically moves to the target
110 position and executes stage backlash correction. Next, image shifts are determined
111 between the drift correction image that was recorded during the setup procedure and a
112 drift correction image that is recorded after arriving at the target location. Any existing
113 shifts are compensated for, using FIB beam shifts, to improve the precision of milling.
114 The rough milling patterns are then exposed, from the highest to the lowest current
115 strength. Previously, manual milling methods used a real-time view in order to determine
116 the time that the FIB needs to cut through the specimen. In our automated approach, the
117 exposure time is calculated by the software using a user-specified milling depth (typically
118 10 μm), milling current, pattern size and material type (e.g. vitrified ice). After exposing
119 the rough milling patterns for the first target, the procedure is automatically repeated for
120 the remaining targets.

121 Subsequently, the user can decide whether to perform polishing for all targets in a manual
122 or automated manner (Fig. 1h). The automation of polishing follows the routine described
123 above.

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127 **Application of sequential automated milling**

128 During the development of this method, we tested automated sequential milling using the
129 model organisms *S. cerevisiae* strain SK1 (hereafter yeast) and the multicellular
130 cyanobacteria *Anabaena* sp. PCC 7120 (hereafter *Anabaena*) in six independent milling
131 sessions (Table 1). The number of attempted lamellae per session ranged from five to 20
132 (Fig. 2). Rough milling success, as defined by the presence of a lamella at the targeted
133 location after rough milling, was 99% (n=73). The only failure in lamella production was
134 the result of a user error, as rough milling was accidentally executed on the same target
135 twice (session F). In session B.1 and B.2, lamellae were successfully generated on ten
136 targets that were spread across two grids containing two different samples (Table 1). This
137 shows the robustness of the targeting routine despite sample variations and the execution
138 of large stage movements during automation.

139 While these results present a significant step forward, we next set out to implement
140 automated sequential lamella polishing. In a series of sessions (B.2-F), we milled between
141 five and 20 targets. In total, the success rate (intact lamella detected after polishing) of
142 automated sequential polishing was 81% (n=57 rough lamellae). Importantly, 9 of the 11
143 failed polishing attempts occurred in session C, in which the rough-milled lamellae were
144 left in the FIB-SEM instrument for 10 h before automated polishing was started. Prior to
145 polishing, these rough lamellae showed signs of bending, which likely resulted in failure
146 in lamellae polishing. Sequential automated lamella polishing should therefore be
147 executed without delay after rough milling. Other reasons for failure in lamella milling
148 could include sample heterogeneity and errors in targeting. If, however, session C were
149 not taken into account, this automated sequential FIB milling methodology would have a
150 95% (n=37) success rate.

151 **Assessment of sample quality**

152 In order to assess sample quality, we transferred the grids from all sessions to the
153 cryoTEM. Of the lamellae that were generated in a fully automated manner, 11% (n=46)
154 were lost in transfer. All remaining lamellae could be imaged by cryoET. From the
155 cryotomograms, we determined the lamellae thicknesses to range from 155 to 379 nm
156 (average 232 nm; final polishing patterns were spaced 300 nm apart) (Supplementary Fig.

157 2). Lamellae that were manually polished (sessions A/B.1) had a comparable average
158 thickness of 258 nm (final polishing patterns were spaced 300 nm apart).

159 CryoET imaging of the automatically generated lamellae revealed distinct cellular
160 features and macromolecular complexes. Yeast tomograms showed a characteristic
161 nucleoplasm, cytoplasmic ribosomes, nuclear envelope, nuclear pore complexes, and
162 cellular compartments (Fig. 3b). *Anabaena* tomograms showed thylakoid membranes,
163 phycobilisomes and septal junctions (Fig. 3c). To further assess sample and data quality,
164 we performed subtomogram averaging of *Anabaena* septal junctions, which had been
165 characterized recently by a manual cryoFIB milling/cryoET approach (Weiss et al.,
166 2019). From nine lamellae, a total of 412 subvolumes were extracted, averaged and
167 classified in order to remove misaligned particles. The 343 remaining subvolumes were
168 then averaged and symmetrized. The resulting structure revealed key features, including
169 a cap module with five arches, a plug module and a tube module (Fig. 3e-h). Fourier shell
170 correlation (FSC) analyses indicate that the average has a resolution that is similar to a
171 structure that was calculated using the same number of particles extracted from
172 tomograms generated in a previous study (Weiss et al., 2019) (manual milling)
173 (Supplementary Fig. 3).

174 **Discussion**

175 In conclusion, our automated sequential cryoFIB milling method allows for the
176 production of high-quality lamellae for cryoET imaging and will impact cryoFIB/cryoET
177 projects in several ways. First, the time investment by the operator is significantly reduced
178 from ~10 h in a manual milling session to ~2.4 h for an automated sequential milling
179 session, assuming 16 targets are milled. Second, by removing the need for frequent user
180 inputs and idle times, the minimum required machine time is reduced from ~38 min
181 (Medeiros et al., 2018) (i.e. 16 lamellae in 10 h) to ~25.5 min (9 min setup plus 16.5 min
182 milling) per lamella. Third, based on the robustness and customizable nature of the
183 method, the procedure can be adapted to a wide range of samples and milling techniques
184 (Toro-Nahuelpan et al.; Wolff et al., 2019). Fourth, the automated procedure will allow
185 the user to systematically explore novel milling methods by reusing uniform milling
186 patterns. Fifth, the method can generally be combined with correlated approaches that
187 allow for target pre-screening, for instance cryo-light microscopy or cryo-FIB-SEM
188 volume imaging (Eibauer et al., 2012; Gorelick et al., 2019; Koning et al., 2014; Schertel

189 et al., 2013; Schorb et al., 2017; Sviben et al., 2016; Vidavsky et al., 2016). That said, the
190 higher throughput achieved by automated cryoFIB milling (shown here) in combination
191 with fast cryoET data collection schemes (Chreifi et al., 2019; Eisenstein et al., 2019),
192 might in many cases eliminate the need for target pre-identification by correlated
193 approaches. Altogether, the development of automated sequential cryoFIB milling
194 renders cryoET applicable to previously unfeasible projects.

195

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202

203 **Methods**

204 Overview of the equipment and workflow

205 The method was established and tested on a Crossbeam 550 FIB-SEM instrument (Carl
206 Zeiss Microscopy) equipped with a copper band-cooled mechanical cryo-stage and an
207 integrated VCT500 vacuum transfer system (Leica Microsystems). The detectors used
208 included an InLens secondary electron (SE) detector for determining grid topology (Carl
209 Zeiss Microscopy) and a SE2 detector for identifying milling targets and assessing the ice
210 thickness (Carl Zeiss Microscopy). In our workflow, EM grids were prepared with
211 budding yeast strain SK1 and *Anabaena* sp. PCC 7120, and clipped into FIB milling
212 Autogrids (ThermoFisher Scientific, Waltham, Massachusetts, U.S.). These grids were
213 then mounted onto a pre-tilted Autogrid holder (Medeiros et al., 2018) (Leica
214 Microsystems) using a VCM loading station (Leica Microsystems). Using the VCT500
215 shuttle, the Autogrid holder was transferred to an ACE600 cryo-sputter coater (Leica
216 Microsystems) under cryogenic conditions and the samples were sputter-coated with a 4
217 nm thick layer of tungsten. After sputter coating, the samples were transferred into the
218 Crossbeam 550 using the VCT500 shuttle. In the Crossbeam 550, the gas injection system
219 (UniGIS) was used to deposit an organometallic platinum precursor layer onto each grid.
220 Automated sequential FIB milling was subsequently set up and executed. Sample
221 preparation, plunge-freezing, Autogrid mounting, holder loading and vacuum cryo-
222 transfer steps were executed similarly to what was described in Medeiros et al. 2018. Any
223 deviations to the previously published protocol are described below.

224 Cell culture and plunge freezing

225 FIB milling tests were performed using the cyanobacterial strain *Anabaena* sp. PCC 7120
226 and the *S. cerevisiae* strain SK1. The *Anabaena* strain was grown and prepared for FIB
227 milling as previously described in Weiss et al. 2019. Yeast cells were prepared as
228 previously described by Medeiros et al. 2018.

229 Equipment calibration

230 To ensure that automated sequential FIB milling was successful, the Crossbeam 550 was
231 properly aligned. While the SEM column alignments are stable and non-essential during
232 automated milling, the FIB alignment between different currents at a given voltage (30

233 kV for biological cryo-samples) should be checked and optimized. Typically, this
234 calibration is done weekly or when deemed necessary and takes roughly 60 min to
235 complete. In case of deviation, on-the-fly adjustments are possible on a loaded cryo-
236 sample, however, standard calibration procedures are best performed on a silicon wafer
237 due to its structural homogeneity, which allows better evaluation of the FIB beam shape.
238 Once inserted into the chamber, the stage was tilted by 54° to be perpendicular to the FIB
239 beam and then moved to the working distance (i.e. coincidence point). Using the ‘spot’
240 function in an unexposed sample region, the beam was focused to its spot size allowing
241 it to burn a hole into the silicon. If the current is properly calibrated, then the beam will
242 produce a spot that is round with sharp edges. This was best seen when using a mixed
243 signal of the InLens and SE2 detector. If a beam spot had imperfections, like a tailing
244 edge, beam parameters including focus, stigmatism and aperture alignments need to be
245 improved and saved. After optimizing these parameters for each current, all currents were
246 aligned against the reference current. This was best performed by centering an easily
247 recognizable structure like a burnt hole for each beam onto the exact position in the image
248 taken with the reference current. Finally, to ensure that the currents were properly aligned,
249 a location is imaged by each current. If properly aligned, switching between currents
250 should not lead to focus changes or beam offsets.

251 Sample coating

252 To enhance sample conductivity and decrease the effects of charging, EM grids were
253 coated with a ~4 nm layer of tungsten using the sputter coating head on the ACE600.
254 After inserting the holder into the FIB-SEM, a protection layer of organometallic
255 platinum precursor was deposited onto each grid to minimize the curtaining effect. For
256 cold deposition of platinum precursor, the holder was moved 3 mm below the coincidence
257 point and was tilted to 20 degrees. By positioning the gas injection system (GIS) needle
258 above each grid and opening the GIS for 30 s, a layer of platinum precursor was deposited
259 onto the sample. Since the GIS needle was mounted at a similar angle as the FIB column,
260 deposition of platinum occurred preferentially on the side of the cells where the FIB beam
261 hits the sample, ensuring the best protection. For deposition under cryo-conditions, it is
262 essential that the heating element of the GIS needle and reservoir are turned off to keep
263 the system at room temperature (28 °C).

264

265 Stage registration

266 To assist in the identification of targets, overview images of an entire EM grid are taken.
267 On the Zeiss Crossbeam 550, these images can be coupled to the stage navigation. To
268 calibrate stage registration a high-resolution (4096 x 3072 pixels, 35x) overview image
269 was taken with the SE2 detector, which provided the best information for identifying
270 targets inside the vitrified ice and determining ice thickness. This overview image was
271 then loaded onto the stage navigation bar and registered by correlating three distinctive
272 points on the image to their specific positions on the stage as observed in the live SEM
273 view. After completion, double clicking on a desired target image location in the
274 navigation bar automatically moves the stage to the location of interest. In addition,
275 backlash correction was also included for all automated stage movements, using the user
276 preference settings of the software SmartSEM (Carl Zeiss Microscopy).

277 Defining milling materials

278 To permit unsupervised automation of lamellae production, the Crossbeam 550 was
279 calibrated to mill a cross-section with a specified depth through the sample. To ensure
280 proper milling, the system needs to be calibrated for a distinct ‘material’ so that the correct
281 milling parameters like dose are applied during milling. For cryo-TEM lamella
282 preparation the material “vitrified ice” was created using a dose calibration of 20 mC /
283 cm² being equivalent to a milling depth of 1 μm in cross-section mode.

284 Parameters for imaging and milling

285 For SEM imaging, voltages from 1.9 - 5 kV and a constant current of 28 pA were used.
286 To capture SEM images, we most commonly used the InLens detector to obtain surface
287 information of the sample. During FIB imaging, on the other hand, a fixed voltage of 30
288 kV and a low current (20pA) was used. FIB images were usually captured by using the
289 SE2 detector, which is less sensitive to imaging-induced charging. During automated
290 sequential milling, four sets of currents above and below the desired lamellae were used.
291 For rough milling 700 pA, 300 pA and 100 pA currents were implemented. To then polish
292 the lamellae, a 50 pA current was used. For milling, we defined the patterns to be executed
293 using bi-directional and cross-section cycle mode with a 10 μm milling depth.

294

295 Automated sequential FIB milling protocol

296 To generate high quality lamellae, it was essential to prepare the FIB-SEM and sample
297 for automated sequential milling. Preparations included checking and calibrating the FIB
298 currents, coating the sample with a layer of tungsten and organometallic platinum, and
299 performing stage registration. Once these steps were executed, automated sequential
300 milling was initiated by identifying and setting up milling targets.

301 The grid overview image in the stage navigator was used to identify a milling target. The
302 identified target was then manually centered in the live FIB view with the aid of the SEM.
303 To improve the accuracy of automated stage movements, backlash correction was
304 performed manually and implemented for all automated stage movements. The target's
305 stage coordinates were then saved in the stage navigator. To ensure that the instrument
306 was able to perform targeting during automation, the stage was manually moved away
307 from the target and then instructed to move back to its saved location. The target was
308 located using the live FIB view and if necessary, manually centered again. If manual
309 centering was required, the new stage location was saved and the instrument's ability to
310 perform targeting was tested again. To ensure successful milling during automation, it
311 was essential to refine the stage location until the stage was able to perform targeting
312 successfully.

313 Once an accurate stage movement was achieved, milling patterns were placed onto a
314 target FIB image captured using SmartFIB. In SmartFIB, each pattern contains specific
315 milling conditions (i.e. current, milling depth, size, shape, etc.) and a designated FIB
316 milling location. SmartFIB allows the placing of multiple patterns with different
317 conditions onto a single FIB image in order to perform automated milling. Patterns were
318 placed and their properties were changed by using the SmartFIB GUI in the 'Attributes'
319 tab. When testing this methodology, we placed eight rectangular milling patterns: six
320 rough milling and two polishing patterns (Supplementary table 1). The final polishing
321 patterns were spaced 300 nm apart, which from our experience results in an average
322 lamella thickness of 225-275 nm. To make uniform lamellae it was also possible to save
323 these eight patterns as a recipe, which can be dragged and dropped onto images of other
324 milling targets. To then save these milling patterns, it was essential to separate the rough
325 and polishing patterns. This was accomplished by deleting the polishing patterns from
326 our recipe, saving only the rough milling patterns, undoing the deletion of the polishing

327 patterns (using the SmartFIB Undo button), deleting all rough milling patterns and then
328 saving only the polishing patterns.

329 To improve the targeting accuracy of this methodology, a drift correction step was also
330 added to each set of rough and polishing milling patterns immediately before being saved.
331 This was done in the SmartFIB ‘attributes’ tab, by capturing and saving an image of a
332 defined region of the FIB view. During the automated protocol SmartFIB would use this
333 image to perform image recognition before beginning milling and compensate for small
334 shifts to ensure the milling patterns are placed correctly on the target. When testing this
335 methodology, it was important to save and then load the same drift correction image for
336 both the rough and polishing milling patterns. This ensured the highest accuracy when
337 moving from rough milling to polishing.

338 After saving a set of rough and polishing patterns, the described method can be repeated
339 for further targets. For an automated protocol, about 9 min were needed to set up each
340 target. It is possible to also automate the milling of targets found on separate EM grids.
341 Once satisfied with the number of targets, all rough milling recipes in the SmartFIB queue
342 were selected and exposed. Exposure of a typical rough milling target takes about 12
343 min. Upon completion, rough milling targets were observed using the SEM and FIB to
344 determine their quality. To then initiate polishing, it is possible to either tick all polishing
345 recipes and expose them, or individually move to each target using SmartFIB, take a FIB
346 image, manually drag polishing patterns into place and expose the lamella. Polishing
347 typically took about 4.5 min. Once all targets are polished, the lamellae are removed from
348 the instrument and stored. It is essential to note that we aimed to keep the lamellae in the
349 instrument for <2 h after beginning polishing to minimize contamination. In theory, this
350 limits our lamellae production to ≤ 20 targets. If, however, aspects including the milling
351 depth, pattern sizes or currents were changed, it would be possible to generate more
352 lamellae. Note that in our attempts, grids with milled lamellae were transported in a dry-
353 shipper from Zeiss Oberkochen, Germany to Zürich, Switzerland prior to cryoET
354 imaging, possibly resulting in some lamellae breaking. An overview of all the milling
355 attempts performed can be found in Table 1.

356 Cryo-electron tomography, tomogram reconstruction and subtomogram averaging

357 Data was collected on a Titan Krios 300kV electron microscope (ThermoFisher)
358 equipped with a field emission gun, imaging filter (Gatan, Munich, Germany) (slit width

359 20 eV) and K2 Summit direct electron detector (Gatan). To generate an overview of each
360 grid, grid montages were collected at 135x magnification using SerialEM (Mastronarde,
361 2005). UCSF Tomo (Zheng et al., 2007) was used for automated recording of tilt series
362 (+60° and -60° tilt range, 2° increments). Data was collected at a defocus of -8 μm, total
363 accumulated dose of ~140 e⁻ / Å² and pixel size of 3.38 Å. Tomogram reconstruction and
364 subtomogram averaging was performed according to Weiss et al. 2019. Briefly,
365 tomograms were reconstructed using the IMOD package (Kremer et al., 1996) and
366 subtomogram averaging was performed using PEET (Nicastro et al., 2006). A total of 412
367 particles were extracted and averaged in a box of 44 x 44 x 44 pixels with a pixel size of
368 0.68 nm. PEET classification was then used to remove misaligned particles (343 final
369 particles). 5-fold symmetry was applied to obtain the final average. The FSC (Fourier
370 Shell Correlation) was generated by using the PEET command calcFSC.

371 Data and code availability

372 Example tomograms of yeast and *Anabaena lamellae* milled in a fully automated manner
373 and the final septal junction subtomogram average determined in this study were
374 deposited to the Electron Microscopy Data Bank (accession number EMDB xxx-yyy for
375 the tomograms and zzz for the subtomogram average).

376

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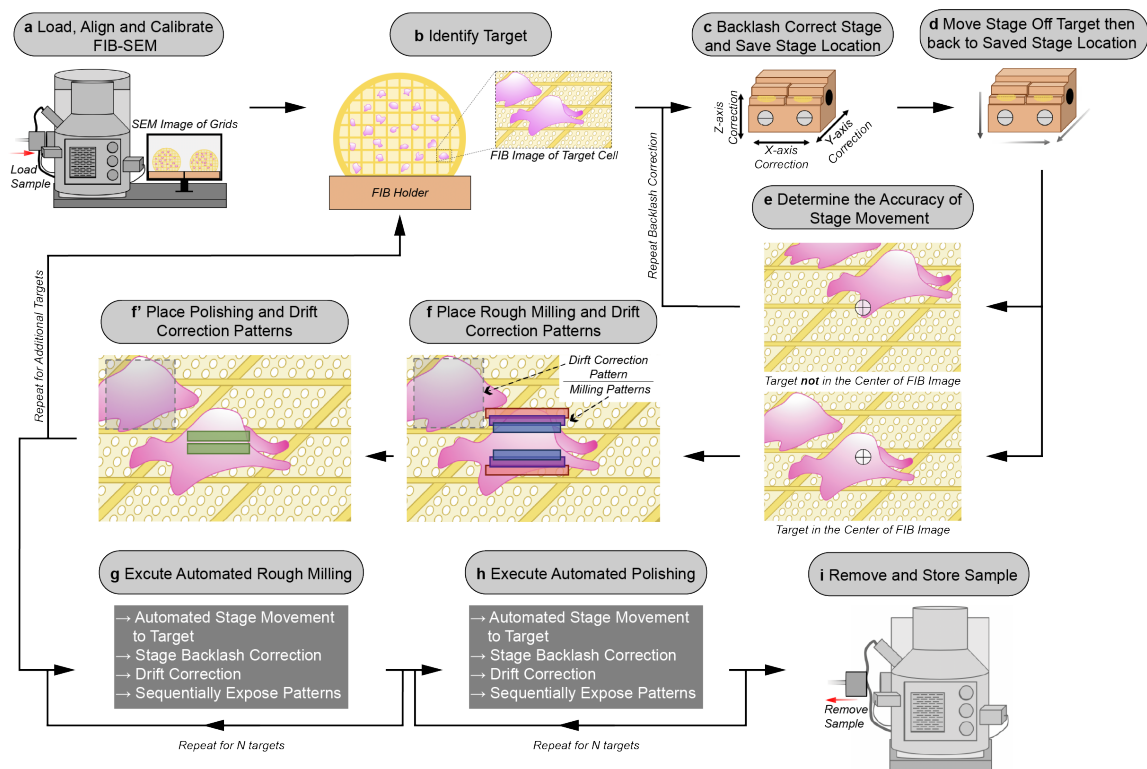
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504 **Figure 1. Schematic of the automated sequential cryoFIB milling workflow.**

505 **a:** FIB currents are aligned and calibrated, and the sample is loaded into the FIB-SEM
506 instrument.

507 **b:** A target cell is identified on the grid with the FIB.

508 **c:** To correct for errors in mechanical stage movements, backlash correction of the stage
509 is performed. The resulting stage location is saved in the stage navigator.

510 **d:** The stage is randomly moved out of position by the user. Using the saved
511 coordinates, the stage is moved back to the target using the saved position in the stage
512 navigator.

513 **e:** The accuracy of this autonomous stage movement is determined by the user. If the
514 target is not centered in the FIB image, backlash correction is repeated until accurate
515 targeting is achieved (c-e).

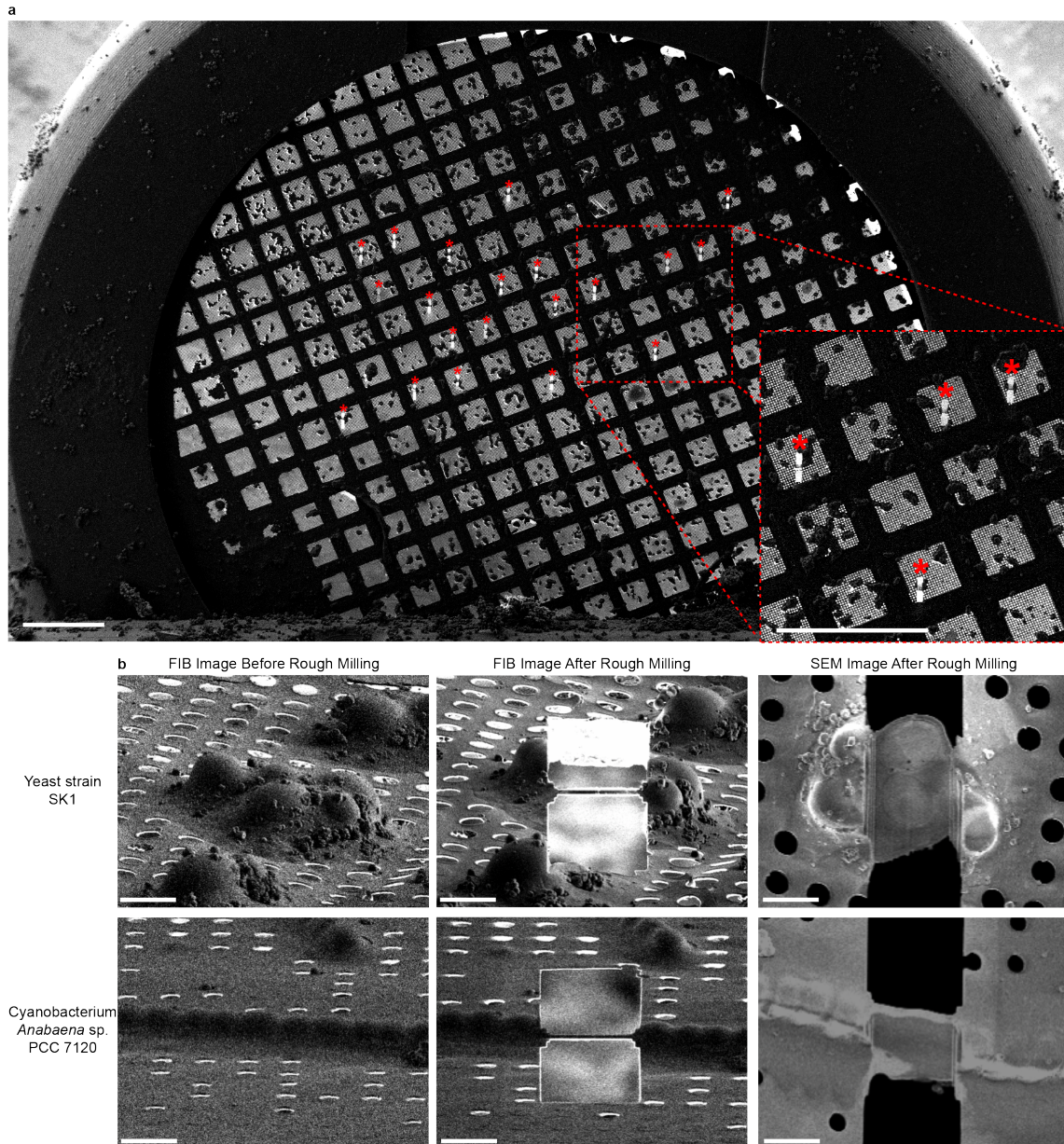
516 **f/f':** Rough milling, polishing and drift correction patterns are placed onto the image.
517 Rough milling and polishing patterns are saved separately to the queue. The procedure
518 (b-f') is repeated to select additional targets.

519 **g/h:** Rough milling and lamellae polishing are executed automatically.

520 **i:** The grids with milled lamellae are removed and stored.

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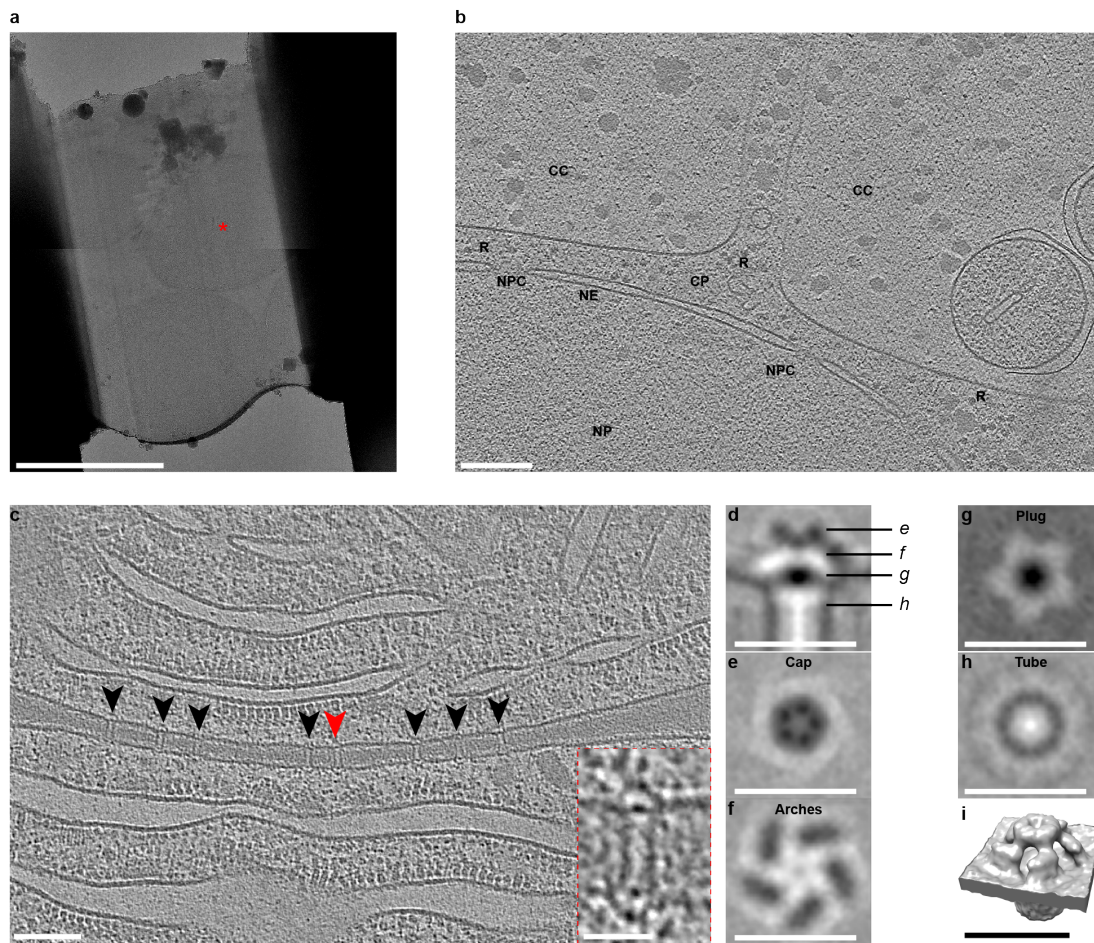
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524 **Figure 2. Representative images of lamellae generated by automated sequential**
525 **rough milling.**

526 **a:** SEM grid overview image including 20 yeast targets (asterisks) on which rough
527 milling was performed in an automated sequential manner (session C). Bars, 200 μm .

528 **b:** Representative SEM and FIB images of yeast and cyanobacterial *Anabaena* cells
529 captured before and after fully automated sequential rough milling (session B.1 and
530 B.2). Bars, 5 μm .

531



532

533 **Figure 3. Automated sequential cryoFIB milling results in high-quality lamellae**
534 **and cryotomograms.**

535 **a:** CryoTEM overview image of a typical lamella (session C) containing multiple yeast
536 cells. Red mark indicates the cell imaged in (b). Bar, 5 μ m.

537 **b:** Shown is an 18 nm thick slice through a cryotomogram of a yeast cell (session C)
538 [indicated by red mark in (a)]. The thickness of the lamella was determined to be 225
539 nm. The tomogram shows a characteristic nucleoplasm (NP), nuclear pore complexes
540 (NPC), nuclear envelope (NE), cytoplasm (CP), cytoplasmic ribosomes (R), and other
541 cellular compartments (CC). Bar, 200 nm.

542 **c:** Shown is a 14 nm thick slice through a cryotomogram of a septum between two
543 *Anabaena* sp. PCC 7120 cyanobacteria cells (session F). The thickness of the lamella
544 was determined to be 208 nm. Arrowheads indicate septal junctions. The inset shows a
545 magnified view of the septal junction indicated by a red arrowhead. Other cellular
546 features are cytoplasmic membranes (CM), phycobilisomes (PB), thylakoid membranes

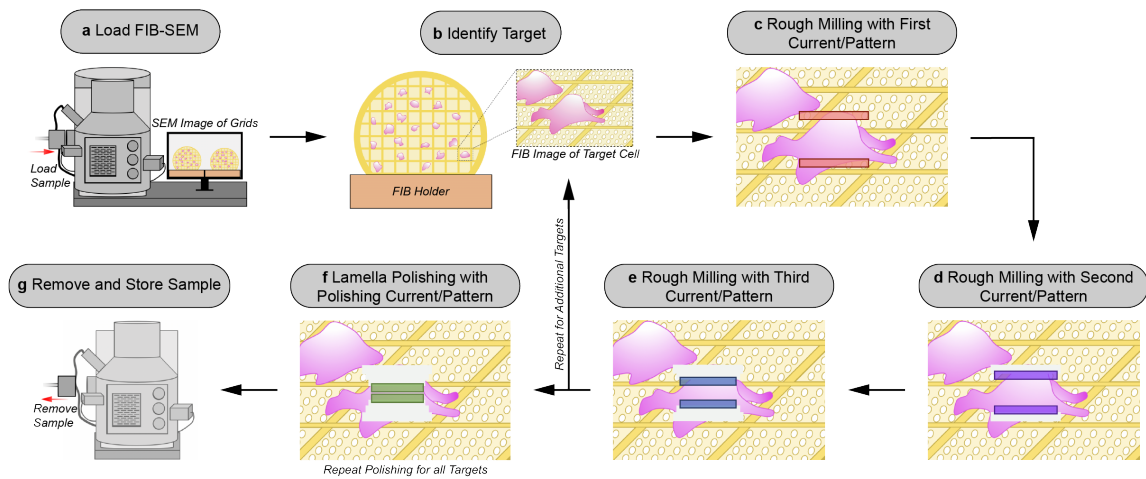
547 (TM) and septal peptidoglycan (PG). Bars, 100 nm and 25 nm (inset).

548 **d-i:** A subtomogram average was generated by 5-fold symmetrizing 343 septal junctions
549 that were extracted from nine tomograms. Shown are longitudinal (d) and perpendicular
550 (e-h) slices (thickness 0.68 nm) and a surface rendering (i) of the symmetrized average.
551 The observed characteristic structural modules were similar to a recent study that
552 applied manual cryoFIB milling (Weiss et al., 2019) (also see Supplementary Fig. 3).
553 Bars, 25 nm.

554

555 **Table 1. Overview and success rates of milling sessions.**

Session	Sample Type	Rough Milling	Rough Milling Success	Polishing	Polishing Success	Comments
A	Cyanobacterium <i>Anabaena</i> sp. PCC 7120	Automated	10/10	Manual	10/10	
B.1	Yeast strain SK1	Automated	5/5	Manual	5/5	Rough milling of both samples performed in the same session.
B.2	Cyanobacterium <i>Anabaena</i> sp. PCC 7120	Automated	5/5	Automated	5/5	
C	Yeast strain SK1	Automated	20/20	Automated	11/20	Lamella were left in instrument for 10h before polishing, leading to lamellae bending and a lower success rate.
D	Cyanobacterium <i>Anabaena</i> sp. PCC 7120	Automated	7/7	Automated	7/7	
E	Cyanobacterium <i>Anabaena</i> sp. PCC 7120	Automated	7/7	Automated	7/7	
F	Cyanobacterium <i>Anabaena</i> sp. PCC 7120	Automated	18/19	Automated	16/18	User selected one target two times for rough milling, leading to failure in rough milling.
		Total Automated	72/73 (99%)	Total Automated	46/57 (81%)	



556

557 **Supplementary Figure 1. Schematic of the manual cryoFIB milling workflow.**

558 **a:** The sample is loaded into the FIB-SEM instrument.

559 **b:** A target is centered in the FIB image.

560 **c-e:** The first pair of rough milling patterns is placed on the target and milling is
561 executed (c). Lamellae milling is observed via a live FIB view to determine when a
562 milling step is completed. The same procedure is repeated for the second (d) and third
563 (e) rough milling patterns. After rough milling of the target is completed, additional
564 targets can be milled by repeating steps b-e.

565 **f:** Rough-milled lamellae are polished with a fourth set of milling patterns. Polishing is
566 repeated for all rough-milled lamellae.

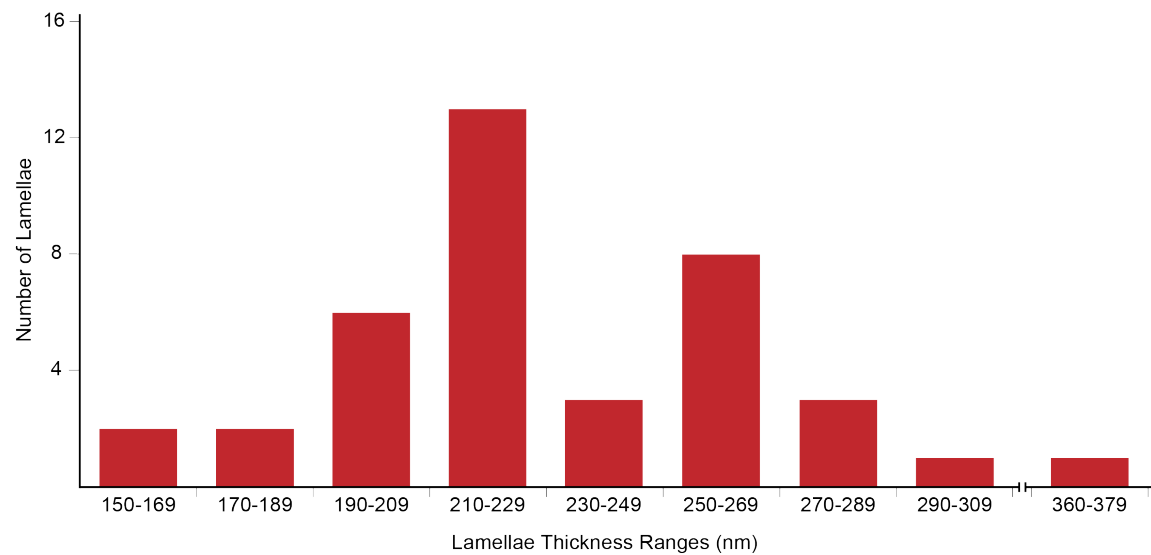
567 **g:** The grids with milled lamellae are removed and stored.

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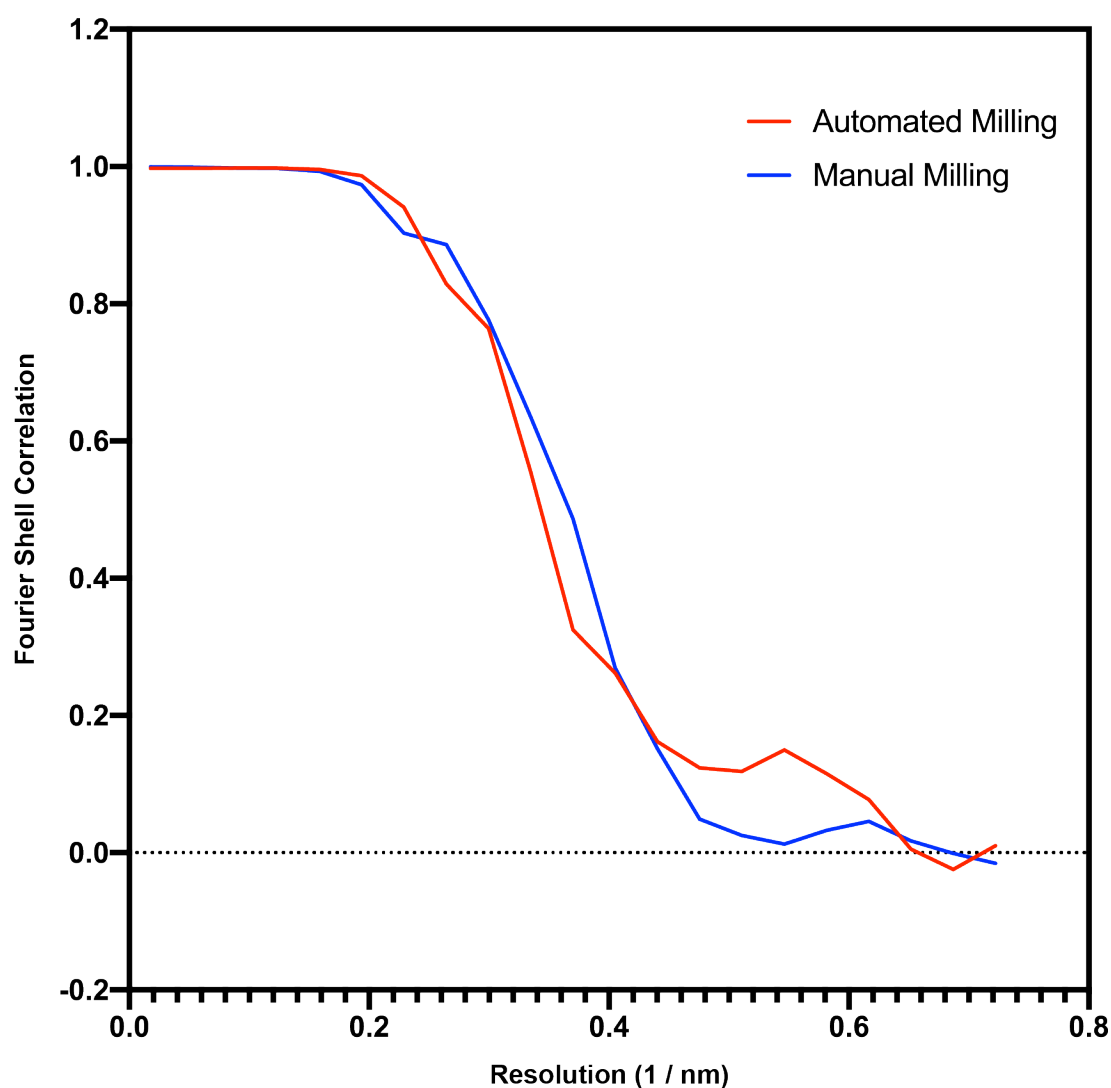


572

573 **Supplementary Figure 2. Distribution of lamellae thickness.**

574 The plot shows the distribution of the thickness values of fully automated sequential
575 FIB-milled lamellae, as determined by cryoET imaging. The final polishing milling
576 patterns were spaced 300 nm apart.

577



578

579 **Supplementary Figure 3. Comparison of data quality between manual and**
580 **automated milling.**

581 Shown is a Fourier Shell Correlation (FSC) curve (blue) for the septal junction
582 subtomogram average shown in Figure 3i (resulting from automated milling). The
583 second curve (red) results from a dataset published previously (Weiss et al., 2019)
584 (resulting from manual milling) and was calculated with the same number of randomly
585 selected subvolumes after 5-fold symmetrization (n=1715). Both approaches result in a
586 comparable resolution estimate.

587

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589

590 **Supplementary Table 1. Dimensions and currents used for each milling pattern**
591 **during automated sequential lamellae preparation.**

Milling Patterns 1 and 2 (Rough Milling 1)	30 kV 700 pA 9 x 5 μm rectangle Patterns spaced 2 μm apart
Milling Patterns 3 and 4 (Rough Milling 2)	30 kV 300 pA 8 x 2 μm rectangle Patterns spaced 1 μm apart
Milling Patterns 5 and 6 (Rough Milling 3)	30 kV 100 pA 7.5 x 1 μm rectangle Patterns spaced 500 nm apart
Milling Patterns 7 and 8 (Lamella Polishing)	30 kV 50 pA 7 x 0.5 μm rectangle Patterns spaced 300 nm apart
Drift Correction Pattern (Rough Milling and Polishing)	3 x 3 μm rectangle

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